ABSTRACT

To provide a novel polishing composition which contributes to improvement of level difference performance (in particular, erosion).

The polishing composition used for polishing an object to be polished includes abrasive grains and a dispersing medium, wherein the abrasive grains have an average primary particle size of 40 nm or less, and the number of coarse particles having a particle size of 0.2 to 1,600 μm in the abrasive grains is 20,000 or less per 1 cm^3 of the polishing composition.